IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re United States Patent Application of: Docket No.: 2771-688 Applicants: KING, Mackenzie, et al. Conf. No.: 7009 Application No.: 10/722,174 Art Unit: 1742 Date Filed: November 25, 2003 Examiner: Nicholas A. Smith Title: ON-WAFER Customer No.: ELECTROCHEMICAL DEPOSITION PLATING METROLOGY PROCESS AND APPARATUS

CERTIFICATE OF EFS FILING

I hereby certify that this document is being filed via EFS in the United States Patent and Trademark Office on May 9, 2008.

//Steven J. Hultquist/

RESPONSE TO APRIL 10, 2008 ADVISORY ACTION AND SUBMISSION OF REQUEST FOR CONTINUED EXAMINATION (RCE) IN U.S. PATENT APPLICATION NO. 10/722.174

Mail Stop RCE Commissioner for Patents P.O. Box 1450 Alexandria, Virginia 22313-1450

Sir:

This responds to the April 10, 2008 Advisory Action in the above-identified application.

In view of the finality of the November 9, 2007 Office Action, a petition for a two-months extension of time is hereby requested under the provisions of 37 CFR 1.136, extending the deadline for reply to the November 9, 2007 Office Action to May 9, 2008. The fee specified in

37 CFR 1.17 for such extension of time is being paid by on-line payment at the time of EFS filling of this Response. It is noted that in connection with the Response to the November 9, 2007 Office Action filed on March 10, 2008, a prior extension of time to March 10, 2008 had been obtained, and the applicable fee paid at that time.

A Request for Continued Examination (RCE) is enclosed and submitted herewith, to continue the examination proceedings involving this application. The fee for such RCE is being paid at the time of EFS submission of this Response.

Please amend the claims of the above-identified patent application as set out in Section I (Amendments to the Claims) hereof.

Remarks concerning the amendments to the claims and the substance of the April 10, 2008 Advisory Action are set out in **Section II (Remarks)** hereof.